PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Junji FUJIKAWA et al

Art Unit:

S. N.

Examiner:

International S.N.: PCT/JP00/06038

RECEIVED

Filed:

International Filing Date: 6 September 2000

31 MAY 2001

For: HALFTONE PHASE SHIFT PHOTOMASK,

AND HALFTONE PHASE SHIFT PHOTOMASK BLANK FOR THE FABRICATION OF THE SAME

US

Legal Stoll
International Division

LETTER

Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

Please note that on the documents (declaration, inventor information sheet, etc.) submitted with this application, the spelling of the first name of the third inventor is different from that given in the International application. The difference is due to a typographical error made during the International phase and the third named inventor should correctly be listed as Takafumi Okamura as submitted herewith to the U.S. Patent and Trademark Office.

Respectfully submitted,

James H. Walters, Reg. No. 35,731

802

DELLETT AND WALTERS

Suite 1101

310 S.W. Fourth Avenue

Portland, Oregon 97204

(503) 224-0115

DOCKET: A-398